# **EUDET Prototype – The next months**

Roman Pöschl

LAL Orsay EUDET Mechanics Meeting 28/8/08

- Timelines
- ECAL Design Note
- Next major meetings Manchester/Amsterdam

### Time Lines

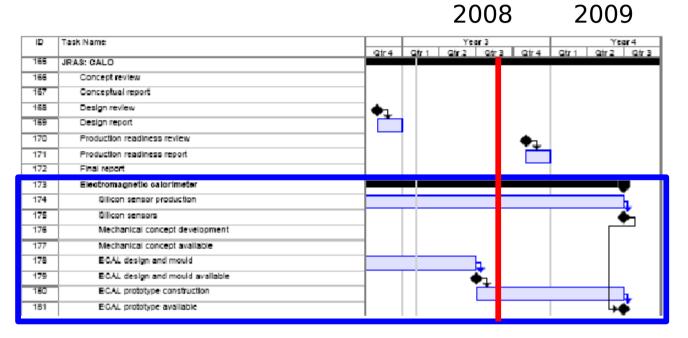
### Demonstrator

- Allows for studying important steps and items of Module production now
- Essential Pieces ready
   Structures and H boards
   FEV6 PCB for temperature
   studies
   Prediction from simulation do exist
   Gluing feasible
   Glass Plates will mimic Si Wafers
- Mimicking of DIF?
- What else?

Assembly can start now Tests until end of 2008

### **EUDET Protoype**

- Design need to be fixed now!!!
   What can we build with the knowledge of today?
- Note on Ecal Design until Amsterdam
- Ordering of pieces for moulds by end of the fiscal year 08 (30<sup>th</sup> November)



We are here
At least ~3 Months of delay

# **Ecal Design Note**

Author (the)

Editorial Work: R.P.

Chapter

Chapter	Author (tbc)
1) Introduction and Purpose	R.P.
2) Overall Design	Marc, Aboud, R.P.
3) Structures and Moulds	Marc
4) Si Wafers	Remi
5) SKIROC Chip	Julien F.
How detailed?	
6) PCB and ASU + Interconnection	Julien F., Maurice, Patrick
How detailed?	
7) DIF Card	Maurice, Bart
8) Gluing Wafer <-> PCBs	David, Ray
9) Heat Dissipation of EUDET Module	Denis, Julien G.
10) Assembly of Prototype	Aboud
11) First Validation Steps – The Demonstrator	R.P., Marc
12) Conclusion and Outlook	R.P.

Note should describe the state of the Art of today and what realistically can be built Not what we may expect in one year, note improvements are always welcome

Deadline 30<sup>th</sup> of September (to be negociated on Mondays exSB Meeting)

# Settling down the design ...

# The expected heat shield thickness is 500 µm=100+400 µm:

1mm

⇒ Brazing of copper foils (T<300°C) to be validated

Heat shield: 100+400 µm

PCB: 800 µm

glue: <100 µm

(needs tests)

wafer 320 µm

(copper)

Heat shield: 100 (housing Al or CuBe?) + 300 or 400 µm Cu = 4 options for copper assembling to test:



Galorimeter for ILC

#### Options 1

100μm housing Cu.. + 400 μm Cu (without brazing – with holes) / 0.4 mm considered for simulation. Thermal grease only in holes (1.8x1.8 cm<sup>2</sup> chips\*400 µm thick).

### Options 2

100μm housing Cu.. + 400 μm Cu + 0.05 (silver brazed) / 0.5 mm considered for simulation. Thermal grease only in holes  $(1.8x1.8 \text{ cm}^2 \text{ chips}^*400 \mu\text{m} \text{ thick})$ .

### Options 3

 100μm housing Cu.. + 300 μm Cu + 0.05 (silver brazed) / **0.4 mm** considered for simulation. Thermal grease only in holes (1.8x1.8 cm<sup>2</sup> chips\*300 µm thick).

### Options 4

100μm housing Cu.. + 400 μm Cu (whithout brazing) / 0.4 mm considered for simulation. No holes (1.8x1.8 cm<sup>2</sup>), chip no overlapping.

# - Design close to 'Option 1' but ...

Kapton film 100 µm

Baseline was: 100μm Al housing and 1.3x1.3cm<sup>2</sup> holes for chips? Need to consider 1.2mm for PCB!!



Chip without packaging

### Next major meetings

### Manchester - CALICE Meeting

- Who will go?
- Occasion for face to face meetings and discussions Agenda needs still to be settled
- <u>Latest</u> date for settling down the design
- Overview talks in Ecal Session
   By whom? Initial Proposal Marc, Remi and Julien

### Amsterdam – EUDET Annual Meeting

- Who will go?
- What to present?
   Two presentations
   Overall status of the Project ~ Summary of the Design Note
   A short dedicated talk on the demonstrator?